

APR 1 4 2003

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

ATSUSHI SHIOTA ET AL.

SERIAL NO: 09/770,289

FILED: JANUARY 29, 2001

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: GROUP ART UNIT: 1712

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: EXAMINER: FEELY, M.

FOR: PROCESS FOR PRODUCING
SILICA-BASED FILM, SILICA-
BASED FILM, INSULATING FILM,
AND SEMICONDUCTOR DEVICE

RECEIVED
APR 22 2003
TC 1700

AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

In response to the Office Action dated December 18, 2002, please amend the
application identified above as follows: